

PRODUCT/PROCESS CHANGE NOTIFICATION

PCN IPD-IPC/12/7320 Dated 13 Aug 2012

Bipolar products changing wafer size from 5" to 6" in Ang Mo Kio fabs (Singapore)

Table 1. Change Implementation Schedule

Forecasted implementation date for change	10-Aug-2012
Forecasted availability date of samples for customer	10-Sep-2012
Forecasted date for STMicroelectronics change Qualification Plan results availability	06-Aug-2012
Estimated date of changed product first shipment	12-Nov-2012

Table 2. Change Identification

Product Identification (Product Family/Commercial Product)	see attached list
Type of change	Waferfab process change
Reason for change	Capacity increase
Description of the change	We are going to change the wafer size from 5" to 6" of the products in bipolar technology, in Ang Mo Kio fabs (Singapore).
Change Product Identification	VW or V6 digits on trace code
Manufacturing Location(s)	

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Customer Part numbers list	
Qualification Plan results	

PCN IPD-IPC/12/7320
Dated 13 Aug 2012
Name:
Title:
Company:
Date:
Signature:

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DOCUMENT APPROVAL

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ATTACHMENT TO PCN IPD-IPC/12/7320

WHAT:

We are changing the wafer size from 5" to 6" of our products in bipolar technology, in Ang Mo Kio fabs (Singapore).

WHY:

To increase production capacity and to improve service.

HOW:

The test vehicles used to qualify the 6" are: 1708BA6, L693EA6, L740CA6, L843DA6 and L877EA6.

The package-oriented reliability evaluation and the electrical and parametric test result analysis on these five test vehicles have been positively completed, see the attached Reliability Report.

The change to 6" will be identified on the trace code by the digits "VW" or "V6".

WHEN:

The change from 5" to 6" will be made progressively from August onwards. The first shipments could be from November 2012, depending on the orders volumes to allow phase-out and phase-in.

Samples can be delivered upon request in 6 weeks A.R.O.



Reliability Report

BIPOLAR TECHNOLOGY PRODUCTS WAFER SIZE CHANGE FROM 5" TO 6" in ANG MO KIO FABS, SINGAPORE

General Information

 Product Line TV1
 1708 BA6

 Product division
 IPD- I&PC

 Package
 VFDFPN8 4X4

 Silicon process technology
 BIP (111)

Locations

Wafer fab location ANG MO KIO 6"
Assembly plant location CARSEM S
Reliability assessment Pass

General Information

 Product Line TV2
 L693 EA6

 Product division
 IPD- I&PC

 Package
 PwSO20

 Silicon process technology
 BIP (>6um)

Locations

Wafer fab locationANG MO KIO 6"Assembly plant locationMUARReliability assessmentPass

General Information

 Product Line TV3
 L740 CA6

 Product division
 IPD- I&PC

 Package
 HeptaWatt7

 Silicon process technology
 BIP (>6um)

Locations

Wafer fab location ANG MO KIO 6"
Assembly plant location BOUSKOURA2
Reliability assessment Pass

General Information

 Product Line TV4
 L843 DA6

 Product division
 IPD- I&PC

 Package
 PDIP16

 Silicon process technology
 BIP (>6um)

Locations

Wafer fab locationANG MO KIO 6"Assembly plant locationMUARReliability assessmentPass

General Information

 Product Line TV5
 L877 EA6

 Product division
 IPD- I&PC

 Package
 SO20

 Silicon process technology
 BIP (>6um)

Locations

Wafer fab locationANG MO KIO 6"Assembly plant locationMUARReliability assessmentPass

DOCUMENT HISTORY

Version	Date	Pages	Author	Comment
1.0	1-April-2012		A.Contrafatto	Original document

Issued by Approved by

Antonino Contrafatto Antonino Motta

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1. APPLICABLE AND REFERENCE DOCUMENTS

Document reference Short description

AEC-Q100 : Stress test qualification for integrated circuits 8161393A : General Specification For Product Development

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2. QUALITY AND RELIABILITY EVALUATION OVERVIEW

2.1 Objectives

This report describes all the evaluation activities and the results achieved in order to convert IPC division products in BIPOLAR technology from 5" fab to 6" fabs in Ang Mo Kio – Singapore. BIPOLAR technology is already qualified in AMK 6" fabs, AMK6 and AMJ9.

The five test vehicles used for the qualification are:

- 1708BA6 assembled in VFDFPN 4x4 8L in CARSEM S.
- L693EA6 assembled in PowerSO20 in MUAR.
- L740CA6 assembled in HeptaWatt7 in BOUSKOURA 2.
- L843DA6 assembled in PDIP16 in MUAR.
- L877EA6 assembled in SO20 in MUAR.

The qualification activities include:

- Package-oriented reliability evaluation of 1708BA6, L693EA6, L740CA6, L843DA6 and L877EA6 devices diffused in AMK 6".
- Electrical and parametric test result analysis on the five test vehicles.

According to Reliability Qualification Plan, below is the list of the trials performed:

Package Oriented Tests

- Preconditioning
- High Temperature Storage
- Autoclave
- Thermal Cycles
- Thermal Humidity Storage

2.2 Conclusion

Taking in account the results of the evaluations performed, the wafer size of I&PC Division products in BIPOLAR technology can be changed from 5" to 6" in ANG MO KIO wafer fabs - Singapore.

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3. DEVICE CHARACTERISTICS

3.1 **Traceability**

3.1.1 TV1 - 1708BA6

Wafer fab information		
Wafer fab manufacturing location	ANG MO KIO - SINGAPORE	
Wafer diameter	6 inches	
Wafer thickness	275 μm ±25	
Silicon process technology	BIP (111)	
Die finishing back side	LAPPED SILICON	
Die size	2930x2130μm	
Bond pad metallization layers	AlSiCu	
Die Finish Front	P-VAPOX (Si glass)	
Metal levels	1	

Assembly Information		
Assembly plant location	CARSEM S - MALAYSIA	
Package description	VFDFPN 4X4 8L	
Molding compound	G770H	
Wires bonding materials/diameters	Au/1mils	
Die attach material	QMI519	
Lead solder material	NiPdAu	

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3.1.2 TV2 - L693EA6

Wafer fab information		
Wafer fab manufacturing location	ANG MO KIO - SINGAPORE	
Wafer diameter	6 inches	
Wafer thickness	280 μm ±25	
Silicon process technology	BIP (>6um)	
Die finishing back side	Cr/Ni/Au	
Die size	3280x3080μm	
Bond pad metallization layers	AISi	
Die Finish Front	SiN (nitride)	
Metal levels	1	

Assembly Information		
Assembly plant location	MUAR - MALAYSIA	
Package description	Power	
Molding compound	SUMITOMO 7307A	
Wires bonding materials/diameters	Au/2 mils	
Die attach material	PREFORM Pb/Ag/Sn 97.5/1.5/1	
Lead solder material	Sn	

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3.1.3 TV3 - L740CA6

Wafer fab information			
Wafer fab manufacturing location	ANG MO KIO - SINGAPORE		
Wafer diameter	6 inches		
Wafer thickness	275 μm ±5		
Silicon process technology	BIP (>6um)		
Die finishing back side	Cr/Ni/Au		
Die size	3160x3170μm		
Bond pad metallization layers	AISi		
Die Finish Front	SiN (nitride)		
Metal levels	1		

Assembly Information			
Assembly plant location	BOUSKOURA - MOROCCO		
Package description	HW 7L		
Molding compound	SUMITOMO 6300HR1LD		
Wires bonding materials/diameters	Cu/2 mils		
Die attach material	PREFORM Pb/Ag/Sn 97.5/1.5/1		
Lead solder material	Sn		

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3.1.4 TV4 - L843DA6

Wafer fab information			
Wafer fab manufacturing location	ANG MO KIO - SINGAPORE		
Wafer diameter	6 inches		
Wafer thickness	275 μm ±25		
Silicon process technology	BIP (>6um)		
Die finishing back side	Cr/Ni/Au		
Die size	2814x2795μm		
Bond pad metallization layers	AISi		
Die Finish Front	SiN (nitride)		
Metal levels	1		

Assembly Information				
Assembly plant location	MUAR - MALAYSIA			
Package description	PDIP16L			
Molding compound	PLASKON S-7PG			
Wires bonding materials/diameters	Au/2 mils			
Die attach material	PREFORM Pb/Ag/Sn 97.5/1.5/1			
Lead solder material	Sn			

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3.1.5 TV5 - L877EA6

Wafer fab information			
Wafer fab manufacturing location	ANG MO KIO - SINGAPORE		
Wafer diameter	6 inches		
Wafer thickness	275 μm ±25		
Silicon process technology	BIP (>6um)		
Die finishing back side	Cr/Ni/Au		
Die size	3910x3660μm		
Bond pad metallization layers	AlSi		
Die Finish Front	SiN (nitride)		
Metal levels	1		

Assembly Information				
Assembly plant location	MUAR - MALAYSIA			
Package description	SO 20L			
Molding compound	SUMITOMO EME7026			
Wires bonding materials/diameters	Au/1.5 mils			
Die attach material	HITACHI EN4900			
Lead solder material	NiPdAu			

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4. RELIABILITY TESTS

4.1 Reliability test conditions and results

4.1.1 TV1 - 1708BA6

Packag	e Oriented Test	:S				
Test	Method	Conditions	Sampl e/Lots	Number of lots	Duration	Results Fail/SS
PC	Pre-Conditionin	g: Moisture sensitivity level 3				
		24h bake@125 ℃,192h@30 ℃/60%R.H.	154	1		0/154
TC	Temperature Cycling					
	PC before	Temp. range: -65℃ /+150℃	77	1	500cy	0/77
AC	Autoclave					
	PC before	121℃ 2atm	77	1	168h	0/77
HTS	High Temperature Storage					
	No bias	Tamb=150℃	77	1	1000h	0/77
THS	Temperature Humidity Storage					
	No bias	Ta=85 ℃/85%, R.H.	77	1	1000h	0/77

4.1.2 TV2 - L693EA6

Packag	e Oriented Test	is				
Test	Method	Conditions	Sampl e/Lots	Number of lots	Duration	Results Fail/SS
PC	Pre-Conditioning	ng: Moisture sensitivity level 3				
		24h bake@125 C,192h@30 C/60%R.H.	154	1		0/154
TC	Temperature Cycling					
	PC before	Temp. range: -65℃ /+150℃	77	1	500cy	0/77
AC	Autoclave					
	PC before	121℃ 2atm	77	1	168h	0/77
HTS	High Temperature Storage					
	No bias	Tamb=150℃	77	1	1000h	0/77
THS	Temperature Humidity Storage					
	No bias	Ta=85 ℃/85%, R.H.	77	1	1000h	0/77

4.1.3 TV3 - L740CA6

Packag	e Oriented Tes	ts					
Test	Method	Conditions	Sampl e/Lots	Number of lots	Duration	Results Fail/SS	
TC	Temperature (Cycling					
	·	Temp. range: -65℃/+150℃	77	1	500cy	0/77	
AC	Autoclave						
		121℃ 2atm	77	1	96h	0/77	
HTS	High Tempera	ture Storage			•		
	No bias	Tamb=150℃	77	1	1000h	0/77	
THS	Temperature Humidity Storage						
	No bias	Ta=85 ℃/85%, R.H.	77	1	1000h	0/77	

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4.1.4 TV4 - L843DA6

Packag	e Oriented Tes	ets					
Test	Method	Conditions	Sampl e/Lots	Number of lots	Duration	Results Fail/SS	
TC	Temperature (Cycling					
	·	Temp. range: -65℃/+150℃	77	1	500cy	0/77	
AC	Autoclave						
		121℃ 2atm	77	1	240h	0/77	
HTS	High Temperature Storage						
	No bias	Tamb=150℃	77	1	1000h	0/77	
THS	Temperature Humidity Storage						
	No bias	Ta=85 ℃/85%, R.H.	77	1	1000h	0/77	

4.1.5 TV5 - L877EA6

Packag	e Oriented Test	ts				
Test	Method	Conditions	Sampl e/Lots	Number of lots	Duration	Results Fail/SS
PC	Pre-Conditioning	ng: Moisture sensitivity level 3				
		24h bake@125 ℃,192h@30 ℃/60%R.H.	154	1		0/154
TC	Temperature Cycling					
	PC before	Temp. range: -65℃ /+150℃	77	1	500cy	0/77
AC	Autoclave					
	PC before	121℃ 2atm	77	1	168h	0/77
HTS	High Temperat	ure Storage				
	No bias	Tamb=150℃	77	1	1000h	0/77
THS	Temperature Humidity Storage					
	No bias	Ta=85 ℃/85%, R.H.	77	1	1000h	0/77

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5. RELIABILITY TESTS DESCRIPTION & DETAILED RESULTS

5.1 Package oriented tests

5.1.1 Pre-Conditioning

The device is submitted to a typical temperature profile used for surface mounting, after controlled moisture absorption.

The scope is to verify that the surface mounting stress does not impact on the subsequent reliability performance. The typical failure modes are "pop corn" effect and delamination.

5.1.2 Thermal Cycles

The purpose of this test is to evaluate the thermo mechanical behavior under moderate thermal gradient stress. Test flow chart is the following:

- Initial testing @ Ta=25℃.
- Readout @ 200 cycles.
- Final Testing @ 500 cycles @ Ta=25℃.

5.1.3 Autoclave

The purpose of this test is to point out critical water entry path with consequent corrosion phenomena related to chemical contamination and package hermeticity.

Test flow chart is the following:

- Initial testing @ Ta=25℃.
- Final Testing (168hrs) @ Ta=25℃.

TEST CONDITIONS:

- P=2.08 atm
- Ta=121℃
- test time= 168 hrs

5.1.4 High Temperature Storage Life

The device is stored in unbiased condition at the max. temperature allowed by the package materials, sometimes higher than the max. operative temperature.

The scope is to investigate the failure mechanisms activated by high temperature, typically wire-bonds solder joint ageing, data retention faults, metal stress-voiding

5.1.5 Thermal Humidity Storage

The Temperature Humidity Storage follows the same method than Unbiased HAST at lower temperature.

TEST CONDITIONS: 85℃/85% RH.

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6. PROCESS CHANGE CHARACTERIZATION

6.1 Parametric Test and EWS analysis

Parametric test distributions have been analyzed: no significant difference has been observed on any T84 critical parameter between BIPOLAR products diffused on 6" and 5" wafer size in AMK fabs.

EWS yield results and parametric distributions have also been analyzed comparing 6" and 5 " wafer size.

All the results are conforming to the expectations: no significant difference in EWS yield % and in the parametric distributions is highlighted.

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PCN Title: Bipolar products changing wafer size from 5" to 6" in Ang Mo Kio fabs (Singapore)

PCN Reference : IPD-IPC/12/7320 PCN Created on : 29-AUG-2012

Subject : Public Products List

Dear Customer,

Please find below the Standard Public Products List impacted by the change:

ST COMMERCIAL PRODUCT

L200CV L2293Q L2293QTR L293B L293D L293DD L293DD013TR L293E L296 L297/1 L296HT L296P L297D L297D013TR L298HN L298N L298P013TR L298P L4960 L4960H L4962/A L4962E/A L4962EH/A L4963D L4963W L4964 L4963D013TR L4964HT L6506 L6506D L6506D013TR SG2525AN SG2525AP SG2525AP013TR SG3524N SG3524P SG3524P013TR SG3525AN SG3525AP SG3525AP013TR TDE1707BFP TDE1707BFPT TDE1708DFT TDE1737DP TDE1747FP TDE1747FPT TDE1767DP TDE1787ADP TDE1798DP TDE3247FP TDE3247FPT

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